

Upgrading to 500mA of the Stored Beam Current at SORTEC 1-GeV Source Facility

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Abstract

At the SORTEC 1-GeV SR source facility for the study of X-ray lithography, the upgrade of the stored beam current to over 500 mA was performed. The RF cavity power supply was increased from 14 kW to 28 kW together with modification of the RF coupler. In addition, the pumping system and the cooling capacity of the storage ring were also reinforced. Reconstruction work and beam tests for upgrade were carried out for 3 months beginning April '92. A stored beam current of 500 mA was successfully achieved within only 2 weeks after the beam operation was restarted. At present the lifetime has reached 25 h. These results are discussed from the aspects of the key issues for upgrading of the stored current and the SR beam aging effects on the time-evolution of the lifetime.

I. INTRODUCTION

The SORTEC SR facility is the dedicated machine which was constructed mainly for x-ray lithography development and has been successfully operating since October 1989 without serious failures. In order to use this system for SR lithography, the exposure time by SR will be required to be as under as that by conventional optical lithography in high throughput requirements.

To reduce the losses of the beamline at the mirror and the Be window and develop a high sensitive resist and so, a maximum stored beam current of 500mA with lifetime of 20h will be required for SR ring [1]. To achieve this requirement, upgrading of the SR ring to 500 mA was scheduled to begin in April 1992. The preliminary machine studies to solve technical problems had been carried out within the capacity limits of existing SR ring in parallel with the regular operations since November 1990 [2].

II. MAIN ITEMS OF THE UPGRADE [3]

For the upgrade of the stored beam current to 500 mA, the nominal capacity of power supply for RF cavity was

increased from 14 kW to 28 kW by replacing the main power tube RS2012CJ with RS2058CJ. The RF coupler was also replaced to accommodate the increase of nominal capacity of the RF power supply. Figure 1 is a photograph of the upgraded RF power coupler and RF power supply.

In addition, the vacuum system of the storage ring was reinforced by increasing the pumping speed against the higher photo desorption gas under increased beam current. The ultrahigh vacuum pump using NEG modules (SAES WP-1250, ST707) (NEG pump) was newly added to remove H_2 at downstream from of the each straight section where the pressure is relatively higher than that in the each bending section.

The ion clearing voltage to cancel out the beam self field was needed to minimize the reduction of beam lifetime and the increase of beam instability due to extension of beam current. The nominal voltage of power source applied by the existing disk-type ion clearing electrode, installed at seven out of eight straight sections, was increased to 1.5 kV from 500 V. A clearing electrode was newly installed at the one straight section previously not equipped with an electrode. The stripe-type ion clearing electrode, instead of the existing disk-type, was newly installed in each chamber of the NEG pump. The diagram of the vacuum system of the ring is shown in Fig. 2.

The temperature rise due to the increase of beam

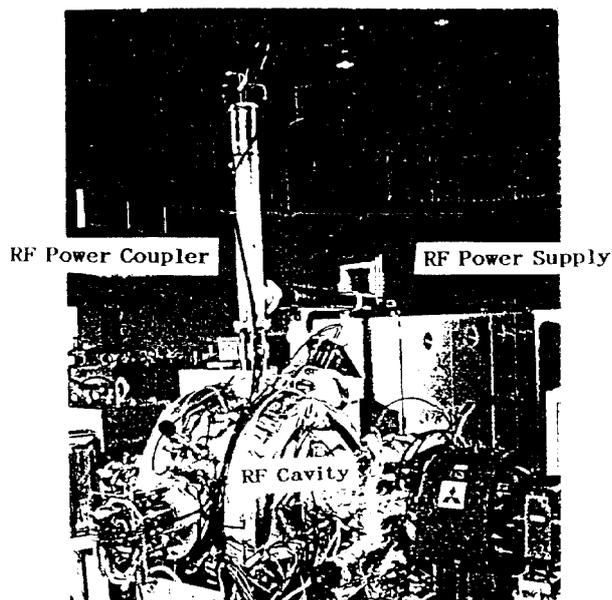


Fig. 1 Photograph of RF coupler and RF power supply.

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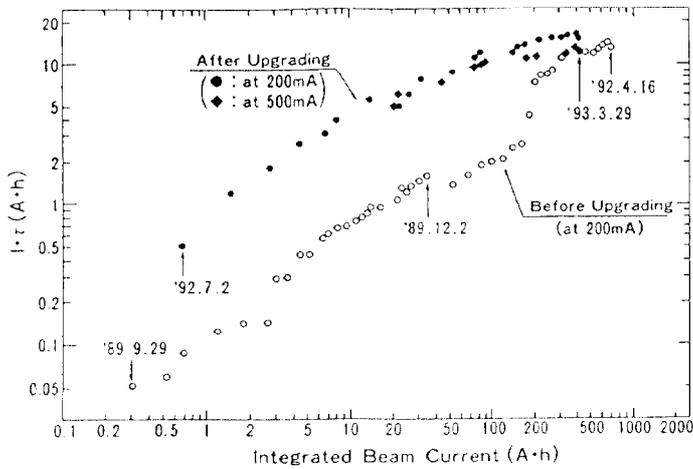


Fig. 6 Improvement of beam lifetime as function of integrated beam current.

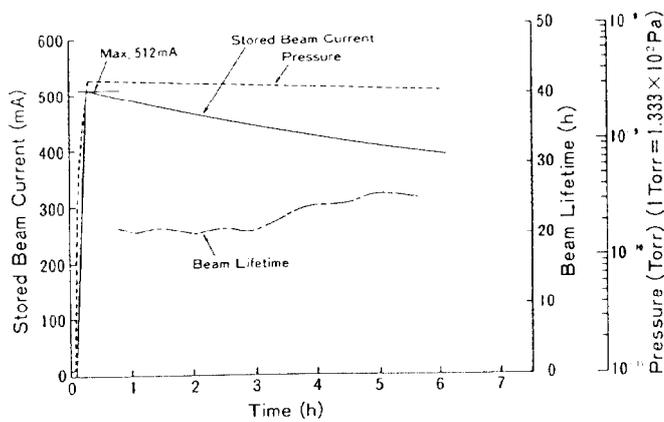


Fig. 7 Typical operation of the facility

Table 1 Main parameters of SR facility at SORTEC.

		Designed	Achieved
Storage Ring			
Energy	GeV	1	1
Dipole Field	T	1.2	1.2
Critical Wavelength	nm	1.55	-
X-Ray Power	kW	15.9	15.9
Beam Current	mA	500	500*
Beam Lifetime	h	>4	>22**
Natural Emittance	mm·mrad	0.51	-
Circumference	m	45.7	-
Synchrotron (Injector)			
Injection Energy	MeV	40	40
Maximum Energy	GeV	1	1
Beam Current	mA	30	50
Circumference	m	43.2	-
Linac (Pre-Injector)			
Energy	MeV	40	40
Beam Current	mA	>30	60~80
Energy Spread	%	<±1.5	±0.67
Emittance	πmm·mrad	<3.8	0.7

* max. 512mA
 ** max. 25h (60h at 200mA)

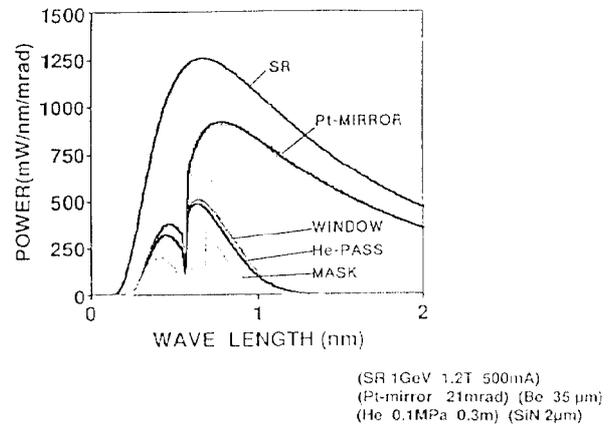


Fig. 8 SR spectrum at 1GeV-500mA SORTEC ring.

vacuum and replacement of the components. This remarkable extension of the lifetime after upgrading mainly depends upon the memory effects of beam duct cleaned by beam dose over a long period. The highest stored beam recorded so far at 1 GeV is 512mA on Oct. 22, 1992, as shown in Fig. 7. The SR ring is filled to 500mA within 10 min. The beam lifetime at 500 mA is 21 h. At present, the maximum beam lifetime reached 25 h in February.

Table 1 summarizes the designed and achieved performance. As a result of the upgrade of the stored beam current to 500 mA from 200 mA, synchronous radiation power was increased by two and a half times. The power density per horizontal angle of 1 mrad ranging from 0 to 2 nm was 1470 mW /mrad. Figure 8 shows the spectrum of synchrotron radiation for the upgraded 1-GeV 500 mA ring.

V. CONCLUSIONS

The works for upgrading has been completed successfully as scheduled with high performance beyond our expectations. As a result of the success of upgrading to 500 mA with over 20 h, the SORTEC 1-GeV SR source has attained top levels all for beam current, beam lifetime and X-ray power as a dedicated SR source for industrial use.

VI. ACKNOWLEDGEMENT

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VI. REFERENCE

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